L Number	Hits	Search Text	DB	Time stamp
1	5451	((250/492.21,423R,423P,492.3) or (315/111.81)).CCLS.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 13:20
2	760	(315/111.81).CCLS.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 13:20
3	92290	ion near implant$8	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 13:21
4	4131	(ion near implant$8) and (photon or photoelectr$3 or photo-electr$3)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 13:40
5	267	(ion near implant$8) and (photon and (photoelectr$3 or photo-electr$3))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 13:40
6	239	((ion near implant$8) and (photon and (photoelectr$3 or photo-electr$3))) and light	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 13:22
7	190	(((ion near implant$8) and (photon and (photoelectr$3 or photo-electr$3))) and light) and (confin$9 or contain$8)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 13:26
8	190	((((ion near implant$8) and (photon and (photoelectr$3 or photo-electr$3))) and light) and (confin$9 or contain$8)) and (semiconductor or wafer or substrate)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 13:26
9	32	(((((ion near implant$8) and (photon and (photoelectr$3 or photo-electr$3))) and light) and (confin$9 or contain$8)) and (semiconductor or wafer or substrate)) and ((space near charge) or (charg$3 near (build$3 or up)))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 13:34
10	17	((((((ion near implant$8) and (photon and (photoelectr$3 or photo-electr$3))) and light) and (confin$9 or contain$8)) and (semiconductor or wafer or substrate)) and ((space near charge) or (charg$3 near (build$3 or up)))) and (ultraviolet or UV or ultra-violet or (ultra adj violet))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 13:28
12	2	(((((((ion near implant$8) and (photon and (photoelectr$3 or photo-electr$3))) and light) and (confin$9 or contain$8)) and (semiconductor or wafer or substrate)) and ((space near charge) or (charg$3 near (build$3 or up)))) and (ultraviolet or UV or ultra-violet or (ultra adj violet))) and magnet$4) and (guid$5 or beamguid$5 or beam-guid$5)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 13:29
11	13	(((((((ion near implant$8) and (photon and (photoelectr$3 or photo-electr$3))) and light) and (confin$9 or contain$8)) and (semiconductor or wafer or substrate)) and ((space near charge) or (charg$3 near (build$3 or up)))) and (ultraviolet or UV or ultra-violet or (ultra adj violet))) and magnet$4	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 13:30

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13	25	(((((ion near implant$8) and (photon and (photoelectr$3 or photo-electr$3))) and light) and (confin$9 or contain$8)) and (semiconductor or wafer or substrate)) and (space near charge)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 13:34
14	2	(((((ion near implant$8) and (photon and (photoelectr$3 or photo-electr$3))) and light) and (confin$9 or contain$8)) and (semiconductor or wafer or substrate)) and ((eliminat$5 or reduc$4 or neutraliz$5) near5 (space near charge))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 13:35
15	268	(ion near implant$8) and ((315/111.81).CCLS.)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 13:40
16	0	((ion near implant$8) and ((315/111.81).CCLS.)) and (photon and (photoelectron or photo-electron))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 13:41
17	3	((ion near implant$8) and ((315/111.81).CCLS.)) and (photoelectron or photo-electron)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 14:03
18	0	6089690.URPN.	USPAT	2004/05/29 13:43
19	160	Sato near Katsuaki	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 13:49
20	4	(Sato near Katsuaki) and (ion adj implant$9)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 14:02
21	516	(photoelectron or photo-electron) and (ion adj implant$9)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 13:52
22	119	((photoelectron or photo-electron) and (ion adj implant$9)) and (ultraviolet or ultra-violet or (ultra adj violet))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 13:53
23	115	(((photoelectron or photo-electron) and (ion adj implant$9)) and (ultraviolet or ultra-violet or (ultra adj violet))) and (confin$5 or contain$5 or eliminat$5 or neutraliz$8)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 13:54
24	10	((((photoelectron or photo-electron) and (ion adj implant$9)) and (ultraviolet or ultra-violet or (ultra adj violet))) and (confin$5 or contain$5 or eliminat$5 or neutraliz$8)) and (space-charge or spacecharge or (space adj charge))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 13:59
26	1	((((((photoelectron or photo-electron) and (ion adj implant$9)) and (ultraviolet or ultra-violet or (ultra adj violet))) and (confin$5 or contain$5 or eliminat$5 or neutraliz$8)) and (space-charge or spacecharge or (space adj charge))) and photon) and ((steer$4 or guid$7) with (ion or beam))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 13:55

25	6	((((photoelectron or photo-electron) and (ion adj implant$9)) and (ultraviolet or ultra-violet or (ultra adj violet))) and (confin$5 or contain$5 or eliminat$5 or neutraliz$8)) and (space-charge or spacecharge or (space adj charge))) and photon	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 13:58
27	0	((((photoelectron or photo-electron) and (ion adj implant$9)) and (ultraviolet or ultra-violet or (ultra adj violet))) and (confin$5 or contain$5 or eliminat$5 or neutraliz$8)) and ((confin$5 or contain$5 or eliminat$5 or neutraliz$8) with (space-charge or spacecharge or (space adj charge)))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 14:00
28	3	((photoelectron or photo-electron) and (ion adj implant$9)) and ((confin$5 or contain$5 or eliminat$5 or neutraliz$8) with (space-charge or spacecharge or (space adj charge)))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 14:02
29	82	("20020014587"|"4383177"|"4447732"|"4686365"|"4780642"|"5024051"|"5350926"|"54	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 14:02
30	53	(("20020014587"|"4383177"|"4447732"|"4686365"|"4780642"|"5024051"|"5350926"|"5 and (ion adj implant$9)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 14:02
31	0	((("20020014587"|"4383177"|"4447732"|"4686365"|"4780642"|"5024051"|"5350926"|" and (ion adj implant$9)) and (photoelectron or photo-electron)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 14:03

L Number	Hits	Search Text	DB	Time stamp
1	5451	((250/492.21,423R,423P,492.3) or (315/111.81)).CCLS.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 13:20
2	760	(315/111.81).CCLS.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 13:20
3	92290	ion near implant$8	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 14:20
4	4131	(ion near implant$8) and (photon or photoelectr$3 or photo-electr$3)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 13:40
5	267	(ion near implant$8) and (photon and (photoelectr$3 or photo-electr$3))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 13:40
6	239	((ion near implant$8) and (photon and (photoelectr$3 or photo-electr$3))) and light	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 13:22
7	190	(((ion near implant$8) and (photon and (photoelectr$3 or photo-electr$3))) and light) and (confin$9 or contain$8)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 13:26
8	190	((((ion near implant$8) and (photon and (photoelectr$3 or photo-electr$3))) and light) and (confin$9 or contain$8)) and (semiconductor or wafer or substrate)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 13:26
9	32	(((((ion near implant$8) and (photon and (photoelectr$3 or photo-electr$3))) and light) and (confin$9 or contain$8)) and (semiconductor or wafer or substrate)) and ((space near charge) or (charg$3 near (build$3 or up)))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 13:34
10	17	((((((ion near implant$8) and (photon and (photoelectr$3 or photo-electr$3))) and light) and (confin$9 or contain$8)) and (semiconductor or wafer or substrate)) and ((space near charge) or (charg$3 near (build$3 or up)))) and (ultraviolet or UV or ultra-violet or (ultra adj violet))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 13:28
12	2	(((((((ion near implant$8) and (photon and (photoelectr$3 or photo-electr$3))) and light) and (confin$9 or contain$8)) and (semiconductor or wafer or substrate)) and ((space near charge) or (charg$3 near (build$3 or up)))) and (ultraviolet or UV or ultra-violet or (ultra adj violet))) and magnet$4) and (guid$5 or beamguid$5 or beam-guid$5)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 14:11
11	13	(((((((ion near implant$8) and (photon and (photoelectr$3 or photo-electr$3))) and light) and (confin$9 or contain$8)) and (semiconductor or wafer or substrate)) and ((space near charge) or (charg$3 near (build$3 or up)))) and (ultraviolet or UV or ultra-violet or (ultra adj violet))) and magnet$4	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 13:30

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13	25	(((((ion near implant$8) and (photon and (photoelectr$3 or photo-electr$3))) and light) and (confin$9 or contain$8)) and (semiconductor or wafer or substrate)) and (space near charge)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 13:34
14	2	(((((ion near implant$8) and (photon and (photoelectr$3 or photo-electr$3))) and light) and (confin$9 or contain$8)) and (semiconductor or wafer or substrate)) and ((eliminat$5 or reduc$4 or neutraliz$5) near5 (space near charge))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 13:35
15	268	(ion near implant$8) and ((315/111.81).CCLS.)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 13:40
16	0	((ion near implant$8) and ((315/111.81).CCLS.)) and (photon and (photoelectron or photo-electron))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 13:41
17	3	((ion near implant$8) and ((315/111.81).CCLS.)) and (photoelectron or photo-electron)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 14:03
18	0	6089690.URPN.	USPAT	2004/05/29 13:43
19	160	Sato near Katsuaki	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 13:49
20	4	(Sato near Katsuaki) and (ion adj implant$9)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 14:09
21	516	(photoelectron or photo-electron) and (ion adj implant$9)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 13:52
22	119	((photoelectron or photo-electron) and (ion adj implant$9)) and (ultraviolet or ultra-violet or (ultra adj violet))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 13:53
23	115	(((photoelectron or photo-electron) and (ion adj implant$9)) and (ultraviolet or ultra-violet or (ultra adj violet))) and (confin$5 or contain$5 or eliminat$5 or neutraliz$8)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 14:15
24	10	((((photoelectron or photo-electron) and (ion adj implant$9)) and (ultraviolet or ultra-violet or (ultra adj violet))) and (confin$5 or contain$5 or eliminat$5 or neutraliz$8)) and (space-charge or spacecharge or (space adj charge))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 13:59
26	1	((((((photoelectron or photo-electron) and (ion adj implant$9)) and (ultraviolet or ultra-violet or (ultra adj violet))) and (confin$5 or contain$5 or eliminat$5 or neutraliz$8)) and (space-charge or spacecharge or (space adj charge))) and photon) and ((steer$4 or guid$7) with (ion or beam))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 13:55

#	Hits	Query	Databases	Date/Time
25	6	(((((photoelectron or photo-electron) and (ion adj implant$9)) and (ultraviolet or ultra-violet or (ultra adj violet))) and (confin$5 or contain$5 or eliminat$5 or neutraliz$8)) and (space-charge or spacecharge or (space adj charge))) and photon	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 13:58
27	0	(((((photoelectron or photo-electron) and (ion adj implant$9)) and (ultraviolet or ultra-violet or (ultra adj violet))) and (confin$5 or contain$5 or eliminat$5 or neutraliz$8)) and ((confin$5 or contain$5 or eliminat$5 or neutraliz$8) with (space-charge or spacecharge or (space adj charge)))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 15:10
28	3	((photoelectron or photo-electron) and (ion adj implant$9)) and ((confin$5 or contain$5 or eliminat$5 or neutraliz$8) with (space-charge or spacecharge or (space adj charge)))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 14:02
29	82	("20020014587"|"4383177"|"4447732"|"4686365"|"4780642"|"5024165"|"5029259"|"5350926"|"54	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 14:02
30	53	(("20020014587"|"4383177"|"4447732"|"4686365"|"4780642"|"5024165"|"5029259"|"5350926"|"5 and (ion adj implant$9)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 14:02
31	0	((("20020014587"|"4383177"|"4447732"|"4686365"|"4780642"|"5024165"|"5029259"|"5350926"|" and (ion adj implant$9)) and (photoelectron or photo-electron)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 14:03
32	0	Kevin near W. near Wenzel	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 14:07
33	1	Kevin near W near Wenzel	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 14:07
34	1	6137112.URPN.	USPAT	2004/05/29 14:08
35	2	Bo near H near Vanderberg	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 14:10
36	0	10/632234	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 14:11
37	0	"10632234"	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 14:11
38	564	(ion near implant$7) and (photoelectron or photo-electron or (photo adj electron))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 14:13
39	714752	((ion near implant$7) and (photoelectron or photo-electron or (photo adj electron))) and lamp or laser	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 14:13

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40	270	((ion near implant$7) and (photoelectron or photo-electron or (photo adj electron))) and (lamp or laser)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 14:13
41	89	(((ion near implant$7) and (photoelectron or photo-electron or (photo adj electron))) and (lamp or laser)) and photon	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 14:14
42	87	((((ion near implant$7) and (photoelectron or photo-electron or (photo adj electron))) and (lamp or laser)) and photon) and (confin$5 or contain$5 or eliminat$5 or neutraliz$8)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 14:15
43	78	(((((ion near implant$7) and (photoelectron or photo-electron or (photo adj electron))) and (lamp or laser)) and photon) and (confin$5 or contain$5 or eliminat$5 or neutraliz$8)) and light	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 14:16
44	37	((((((ion near implant$7) and (photoelectron or photo-electron or (photo adj electron))) and (lamp or laser)) and photon) and (confin$5 or contain$5 or eliminat$5 or neutraliz$8)) and light) and guid$7	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 14:23
46	7	((((((ion near implant$7) and (photoelectron or photo-electron or (photo adj electron))) and (lamp or laser)) and photon) and (confin$5 or contain$5 or eliminat$5 or neutraliz$8)) and light) and ((beam or ion) with guid$7)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 14:18
47	1	(((((((ion near implant$7) and (photoelectron or photo-electron or (photo adj electron))) and (lamp or laser)) and photon) and (confin$5 or contain$5 or eliminat$5 or neutraliz$8)) and light) and ((beam or ion) with guid$7)) and magnet$6	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 14:18
45	7	((((((ion near implant$7) and (photoelectron or photo-electron or (photo adj electron))) and (lamp or laser)) and photon) and (confin$5 or contain$5 or eliminat$5 or neutraliz$8)) and light) and (guid$7 with (beam or ion))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 14:19
48	263	(ion adj implant$8) and ((315/111.81).CCLS.)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 14:22
49	3	((ion adj implant$8) and ((315/111.81).CCLS.)) and (photoelectron or photo-electron or (photo adj electron))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 14:22
50	1454	(ion adj implant$8) and (((250/492.21,423R,423P,492.3) or (315/111.81)).CCLS.)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 15:08
51	12	((ion adj implant$8) and (((250/492.21,423R,423P,492.3) or (315/111.81)).CCLS.)) and (photoelectron or photo-electron or (photo adj electron))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 15:09

52	5	(((ion adj implant$8) and (((250/492.21,423R,423P,492.3) or (315/111.81)).CCLS.)) and (photoelectron or photo-electron or (photo adj electron))) and photon	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 15:09	
54	1	(((((ion adj implant$8) and (((250/492.21,423R,423P,492.3) or (315/111.81)).CCLS.)) and (photoelectron or photo-electron or (photo adj electron))) and photon) and magnet$8) and guid$7	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 14:23	
53	4	((((ion adj implant$8) and (((250/492.21,423R,423P,492.3) or (315/111.81)).CCLS.)) and (photoelectron or photo-electron or (photo adj electron))) and photon) and magnet$8	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 15:09	
55	8	(((ion adj implant$8) and (((250/492.21,423R,423P,492.3) or (315/111.81)).CCLS.)) and (photoelectron or photo-electron or (photo adj electron))) and magnet$8	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 14:32	
56	9	(((ion adj implant$8) and (((250/492.21,423R,423P,492.3) or (315/111.81)).CCLS.)) and (photoelectron or photo-electron or (photo adj electron))) and light	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 15:05	
57	6	((((ion adj implant$8) and (((250/492.21,423R,423P,492.3) or (315/111.81)).CCLS.)) and (photoelectron or photo-electron or (photo adj electron))) and light) and magnet$8	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 15:08	
58	53	(ion adj implant$8) and (("20020014587"|"4383177"|"4447732"|"4686367"...	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 15:...	...642"|"5206516"|"5350926"|"5...
59	0	((ion adj implant$8) and (("20020014587"|"4383177"|"4447732"|"4686367"... and (photoelectron or photo-electron or (photo adj electron))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 15:...	...642"|"5206516"|"5350926"|"5
60	0	((ion adj implant$8) and (("20020014587"|"4383177"|"4447732"|"4686367"... and photon	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 15:...	...642"|"5206516"|"5350926"|"5
61	44	((ion adj implant$8) and (("20020014587"|"4383177"|"4447732"|"4686367"... and magnet$8	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 15:...	...642"|"5206516"|"5350926"|"5
63	45	((315/111.81).CCLS.) and (UV or ultraviolet or ultra-violet or (ultra adj violet))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 15:11	
64	1	(((((ion adj implant$8) and (("20020014587"|"4383177"|"4447732"|"4686367"... and magnet$8) and ((confin$5 or contain$5 or eliminat$5 or neutraliz$8) with (space-charge or spacecharge or (space adj charge)...	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 15:22	...642"|"5206516"|"5350926"|"5
62	11	((((ion adj implant$8) and ultraviolet or ultra-violet or (ultra adj violet)... ((("20020014587"|"4383177"|"4447732"|"4686367"... and magnet$8) and ((confin$5 or contain$5 or eliminat$5 or neutraliz$8) with (space-charge or spacecharge or (space adj charge)...	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 15:32	...642"|"5206516"|"5350926"|"5
65	1	((((ion adj charge) implant$8) and (("20020014587"|"4383177"|"4447732"|"4686367"... and magnet$8) and ((confin$5 or contain$5 or eliminat$5 or neutraliz$8) with (space-charge or spacecharge or (space adj charge)))) and (UV or ultraviolet or ultra-violet or (ultra adj violet) or light)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 15:22	...642"|"5206516"|"5350926"|"5

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66	4	(photoelectron or photo-electron or (photo adj electron)) and (ion near implant$8) and ((confin$5 or contain$5 or eliminat$5 or neutraliz$8) near2 (space-charge or spacecharge or (space adj charge)))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 15:31
67	132	(ion adj implant$8) and (photoelectron or photo-electron) and photon	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 15:31
68	132	((ion adj implant$8) and (photoelectron or photo-electron) and photon) and photon	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 15:32
69	43	(((ion adj implant$8) and (photoelectron or photo-electron) and photon) and photon) and guid$5	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 15:32
70	2	((((ion adj implant$8) and (photoelectron or photo-electron) and photon) and photon) and guid$5) and ((confin$5 or contain$5 or eliminat$5 or neutraliz$8) with (space-charge or spacecharge or (space adj charge)))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 15:33
71	7	(((((ion adj implant$8) and (("20020014587"|"4383177"|"4447732"|"46863693+PGPUB642"|US"5206516"|"5350926"|"5 and magnet$8) and ((confin$5 or contain$5 or eliminat$5 or neutraliz$8) with (space-charge or spacecharge or (space adj charge)) implant$8 and	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 15:33
72	5	(("20020014587"|"4383177"|"4447732"|"46863693+PGPUB642"|US"5206516"|"5350926"|"5 and magnet$8) and ((confin$5 or contain$5 or eliminat$5 or neutraliz$8) with (space-charge or spacecharge or (space adj charge)) implant$8 and aluminum	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 15:33
73	0	(("20020014587"|"4383177"|"4447732"|"46863693+PGPUB642"|US"5206516"|"5350926"|"5 and magnet$8) and ((confin$5 or contain$5 or eliminat$5 or neutraliz$8) with (space-charge or spacecharge or (space adj charge)) implant$8 and aluminum) and	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 15:33
74	0	(("20020014587"|"4383177"|"4447732"|"46863693+PGPUB642"|US"5206516"|"5350926"|"5 and magnet$8) and ((confin$5 or contain$5 or eliminat$5 or neutraliz$8) with (space-charge or spacecharge or (space adj charge)))) and guid$6) and aluminum) and sheath) and analyz$4	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/29 15:33